

國立交通大學

電子工程學系 電子研究所

碩士論文

以準分子雷射結晶與非晶矽間隙壁結構製作
高遷移率複晶矽薄膜電晶體之研究



Study on High-Mobility Polycrystalline Silicon Thin Film Transistors
Fabricated by Excimer Laser Crystallization with
Amorphous Silicon Spacer Structure

研究生：呂健豪

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指導教授：鄭晃忠 博士

Dr. Huang-Chung Cheng

中華民國九十三年六月

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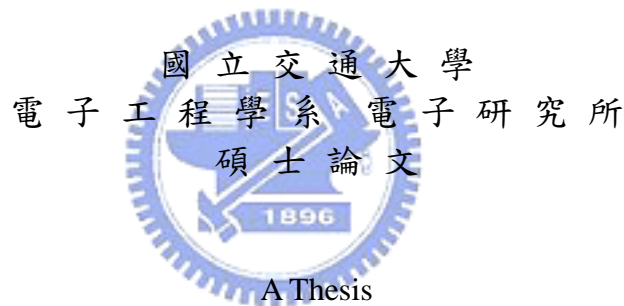
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